	Application No.	Applicant(s)	
Notice of Allowability	10/718,662 Examiner	KAN ET AL. Art Unit	
	LXammer		
	David Lam	2827	
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED or other appropriate comm IGHTS. This application is	in this application. If not included nunication will be mailed in due course. THIS	e
1. This communication is responsive to <u>10/20/06</u> .			
2. The allowed claim(s) is/are 13-19 (renumbered as 1-7).			
 3. Acknowledgment is made of a claim for foreign priority up a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority do 	e been received. e been received in Applicat	ion No	
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		le a reply complying with the requirements	
4. A SUBSTITUTE OATH OR DECLARATION must be subminformal patent application (PTO-152) which give			
5. CORRECTED DRAWINGS (as "replacement sheets") must	st be submitted.		
(a) I including changes required by the Notice of Draftspers	son's Patent Drawing Revie	ew (PTO-948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date			
(b) including changes required by the attached Examiner' Paper No./Mail Date	's Amendment / Comment	or in the Office action of	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the	l.84(c)) should be written on the header according to 37 C	the drawings in the front (not the back) of FR 1.121(d).	
6. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT.			
·.			
Attachment(s)	E Nation of	aformal Potent Application (PTO 152)	
 Notice of References Cited (PTO-892) Dotice of Draftperson's Patent Drawing Review (PTO-948) 	-	nformal Patent Application (PTO-152) Summary (PTO-413),	
	Paper No	./Mail Date	
 Information Disclosure Statements (PTO-1449 or PTO/SB/I Paper No./Mail Date 	,	s Amendment/Comment	
 Examiner's Comment Regarding Requirement for Deposit of Biological Material 	8. 🛛 Examiner	s Statement of Reasons for Allowance	
	9. 🔲 Other	 L 1 7	
		DAVID LAM PRIMARY EXAMINER	•

U.S. Patent and Trademark Office PTOL-37 (Rev. 7-05) Application/Control Number: 10/718,662 Page 2

Art Unit: 2827

Response to Amendment

1. This office action is in response to amendment file on 10/20/06.

- Claims 19 have been cancelled.

- Claims 10-12 are withdrawn from consideration.

- Claims 13-19 are newly added.

- Claims 10-19 are pending in the application.

EXAMINER'S AMENDMENT

2. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

IN THE CLAIM:

- Claims 10-12 have been cancelled due to nonelected without traverse.

Allowable Subject Matter

3. The following is an examiner's statement of reasons for allowance: Claims 13-19 (renumbered as claims 1-7) are allowable over the prior art of record because none of the prior art whether taken singularly or in combination, especially when these limitations are considered within the specific combination claimed, to teach: a multibit storage memory cell comprising: an insulator material formed on a substrate and having a plurality of metal nanocrystals

embedded therein, bias voltages connected to a source drain regions to produce asymmetric charging of the nanocrystals, in combination with others as claimed in the independent claim 13, wherein the metal nanocrystals are formed from a metal that is selected to have a work function valued which effects transport of charge through the insulating material such that a first, low potential barrier is formed across a tunnel oxide during writing to the storage elements, and a second, higher potential barrier is formed across the tunnel oxide during retention of charge in the storage elements.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David Lam whose telephone number is 571-272-1782. The examiner can normally be reached on 6:00-4:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zarabian Amir can be reached on 571-272-1852. The fax phone numbers for the organization where this application or proceeding is assigned is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

Art Unit: 2827

applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

D. Lam

December 14, 2006

DAVID LAM
PRIMARY EXAMINER